DOCKET NO: 251219US2 DIV

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

SHOICHI HARAKAWA ET AL

1

SERIAL NO: NEW DIVISIONAL

APPLICATION

FILED: HEREWITH :

FOR: SEMICONDUCTOR PROCESSING PROCESS CONTROL SYSTEM AND ITS

CONTROL METHOD

PRELIMINARY AMENDMENT

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

Prior to examination on the merits, please amend the above-identified divisional application as follows:

Amendment to the Specification begins on page 2.

Amendments to the Claims begin on page 3 of this paper.

Remarks/Arguments begin on page 6 of this paper.